

Development of Superconducting-Tunnel-Junction Single-Photon-Detectors Integrated with FD-SOI MOSFET Amplifiers

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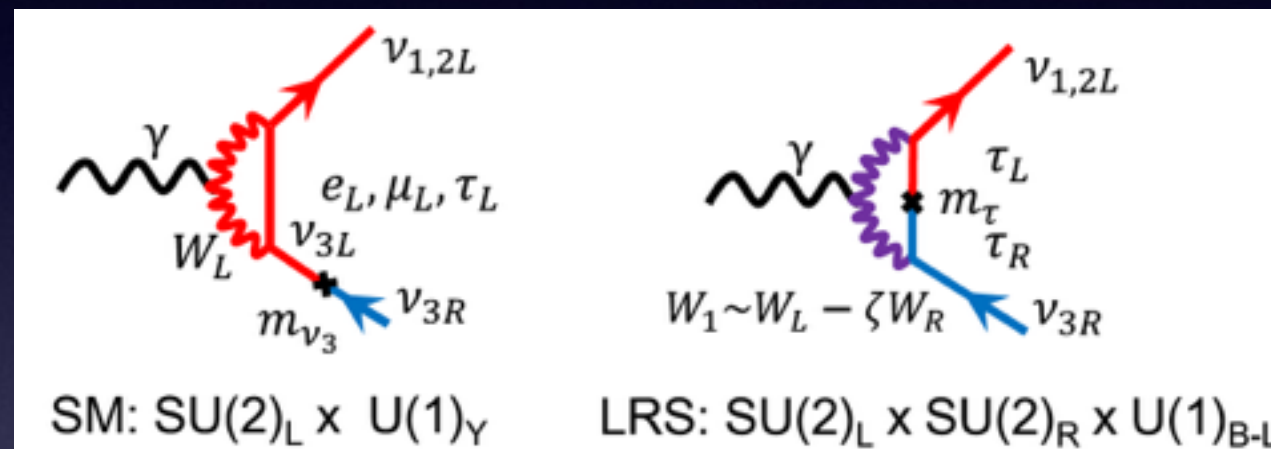
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⁶Kinki University ⁸Fermilab ⁹Seoul National University ¹⁰AIST ¹¹Kansei Gakuin University
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Outline

- Search for the radiative neutrino decay
- The Superconducting Tunnel Junction (STJ)
- The Fully-Depleted Silicon-On-Insulator(FD-SOI) FET based cold amplifier
 - IV characteristics at cryogenic temperature
 - The capacitance of the STJ and readout line
 - The candidate design of cold amplifier for STJ
- Summary

Neutrino radiative decay

Feynman diagrams for the neutrino radiative decay



- Neutrinos have non-zero masses
-> The heavy neutrino can decay into the light neutrino.
- The decay rate is drastically enhanced in the Left - Right symmetric model.

$$\tau_{SM} \approx 10^{43} \text{ years} \quad \tau_{LRSM} \approx 10^{17} \text{ years}$$

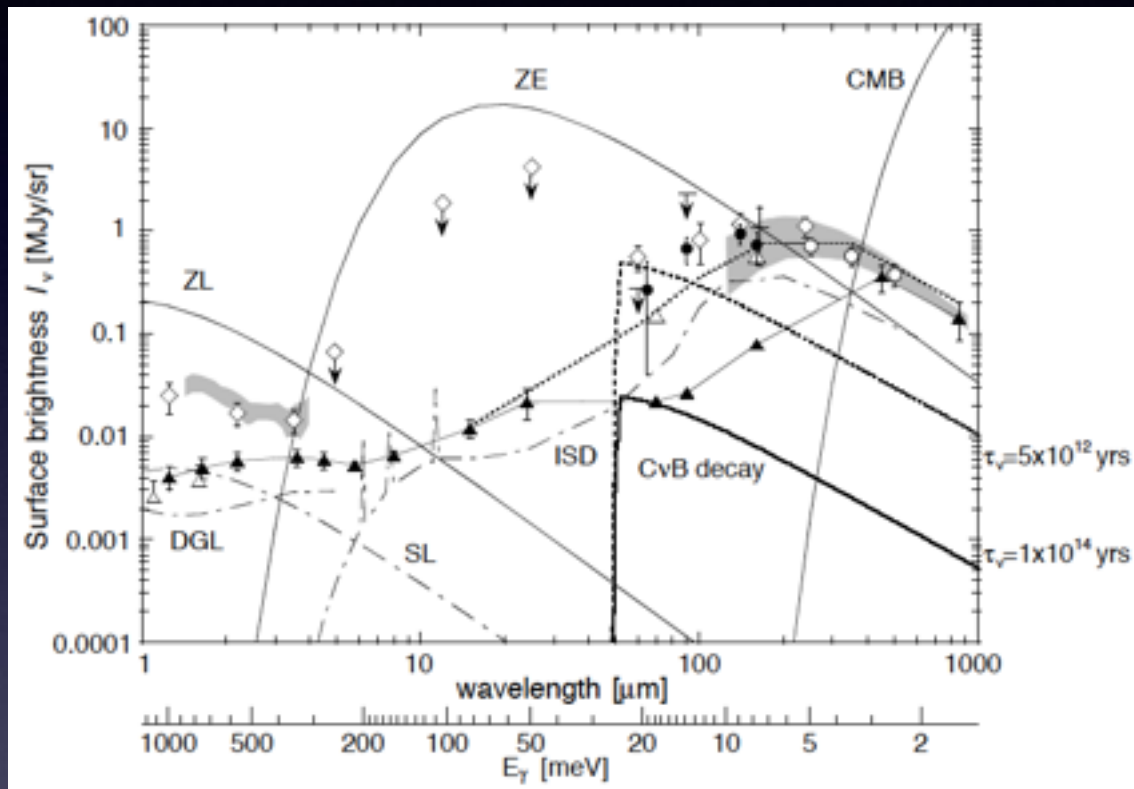
- The cosmic neutrino background(CvB) is a good neutrino source for the neutrino radiative decay search.

Search for the CvB decay

Shape of CvB decay signal

Monochromatic photon
+ Red shift

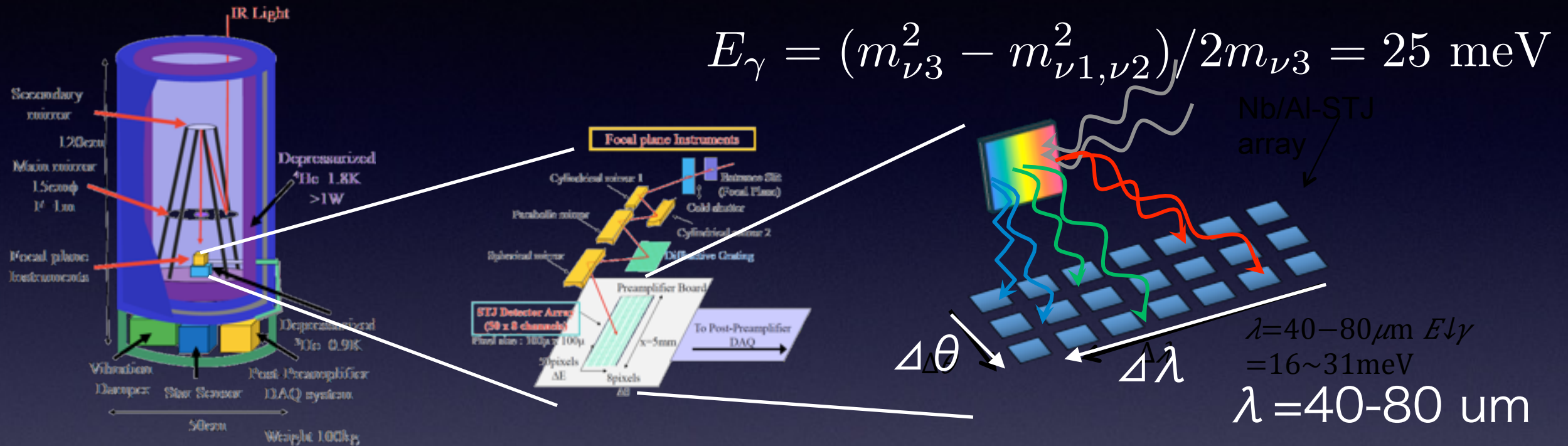
This well known shape is useful
to pick up the signal
from the Zodiacal Emission(ZE)



S. H. Kim, K. Takemasa, Y. Takeuchi and S. Matsuura, J. Phys. Soc. Jpn., 81 (2012) 024101S

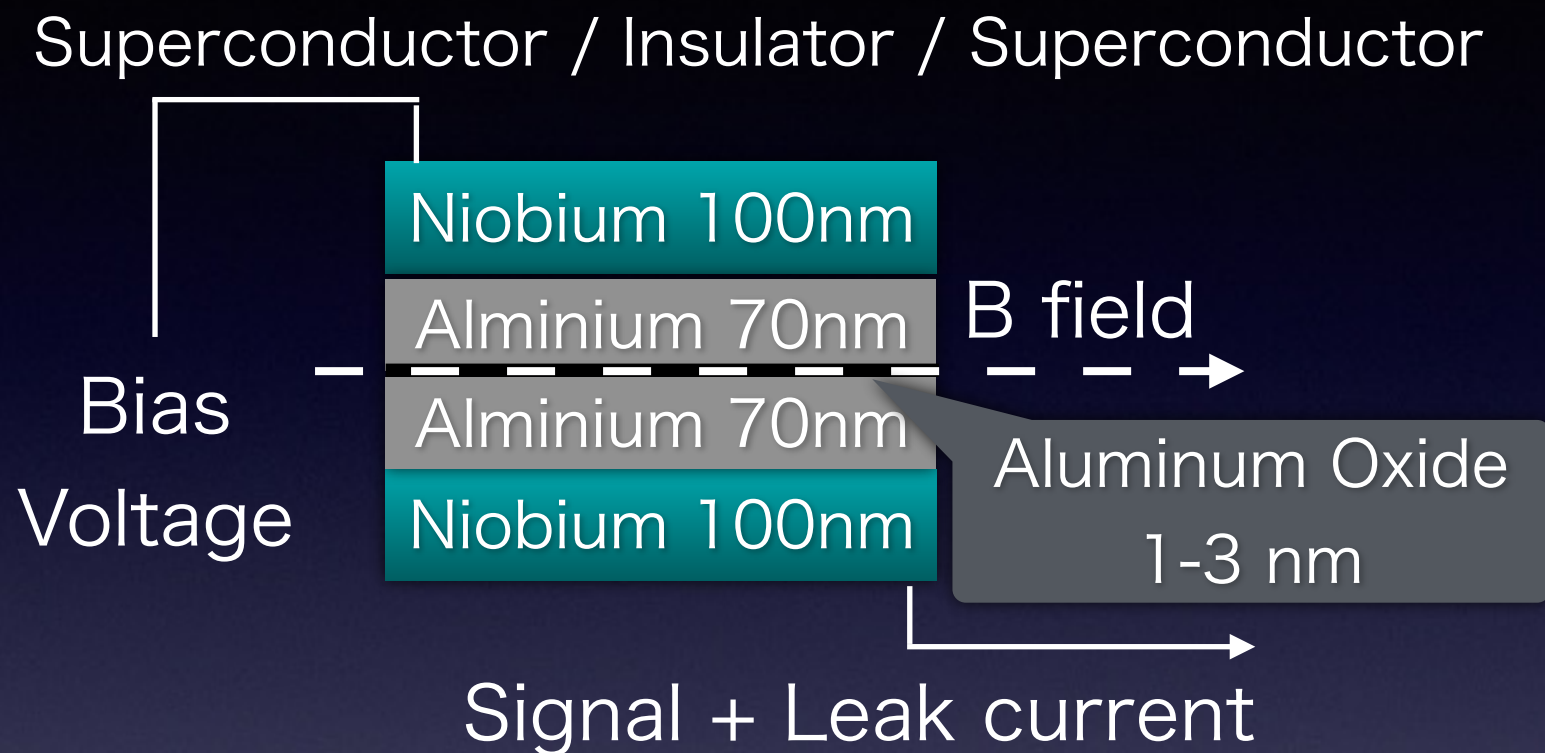
- The energy of photon is expected to be 40μm-80μm
- The current experimental lower limit is $\tau_{\nu 3} = 3 - 4 \times 10^{12}$ years
- Target of our next experiment is $\tau_{\nu 3} = 10^{14}$ years
- We plan to measure the continuous₄distribution of the photon energy

CvB rocket experiment



- Expected observation period is 200sec at an altitude of 200-300km
 - The telescope with diameter of 15cm and focal length of 1m
- The diffraction grating(40-80um) with $\Delta\lambda \times \Delta\theta = 50 \times 8$ STJ pixels
- Detectors must be able to count the single FIR photon with sampling rate of 500kHz to suppress the background due to the dark noise
- Requirements: $Q_{noise} < 30e$ for $2\mu\text{s}$ integration, $I_{\text{dark}} < 0.1\text{nA}$

The Superconducting Tunnel Junctions(STJ)

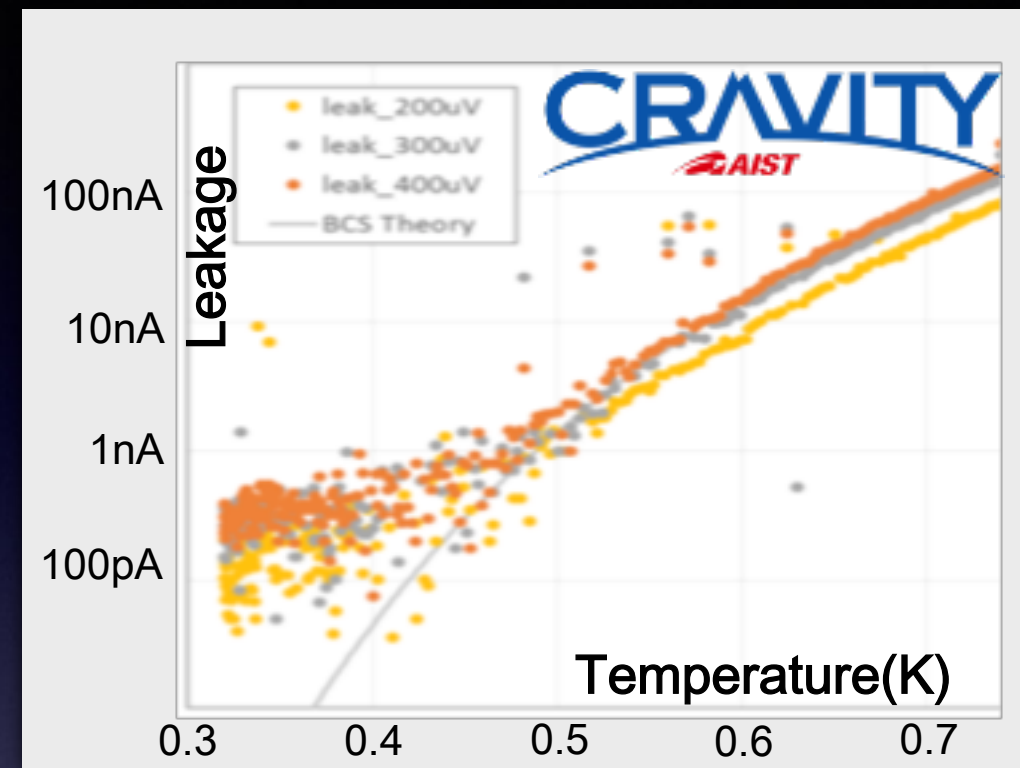
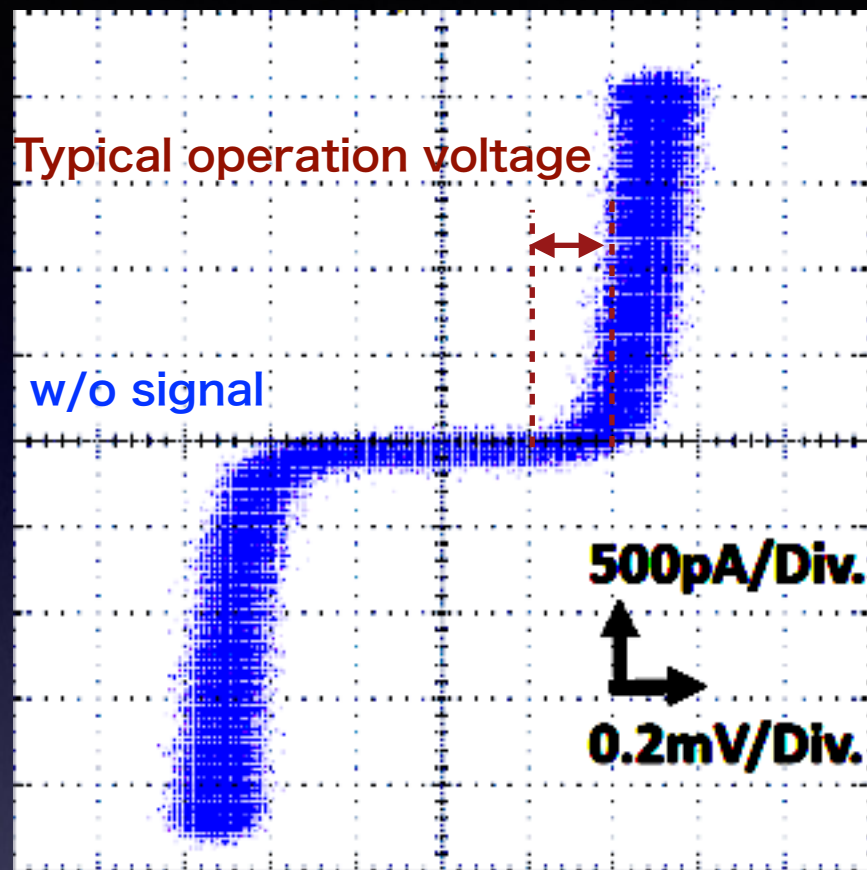


- The superconductor has a tiny band-gap
- The number of excited electron is proportional to the deposited energy. $N_e = E / 1.7 \Delta$
- The response time is a few μs
 - Suitable for single photon detection
- Insulation layer must be thin, since STJ is a tunnel device
- STJ have an large capacitance with a high leak current

	Al	Nb	Si
Energy gap (meV)	0.172	1.55	1100
Critical temperature (K)	1.2	9.2	-

The Nb/Al bi-layer has an energy gap and T_c between pure Nb and Al (proximity effect)

The IV characteristic of Nb/Al-STJ

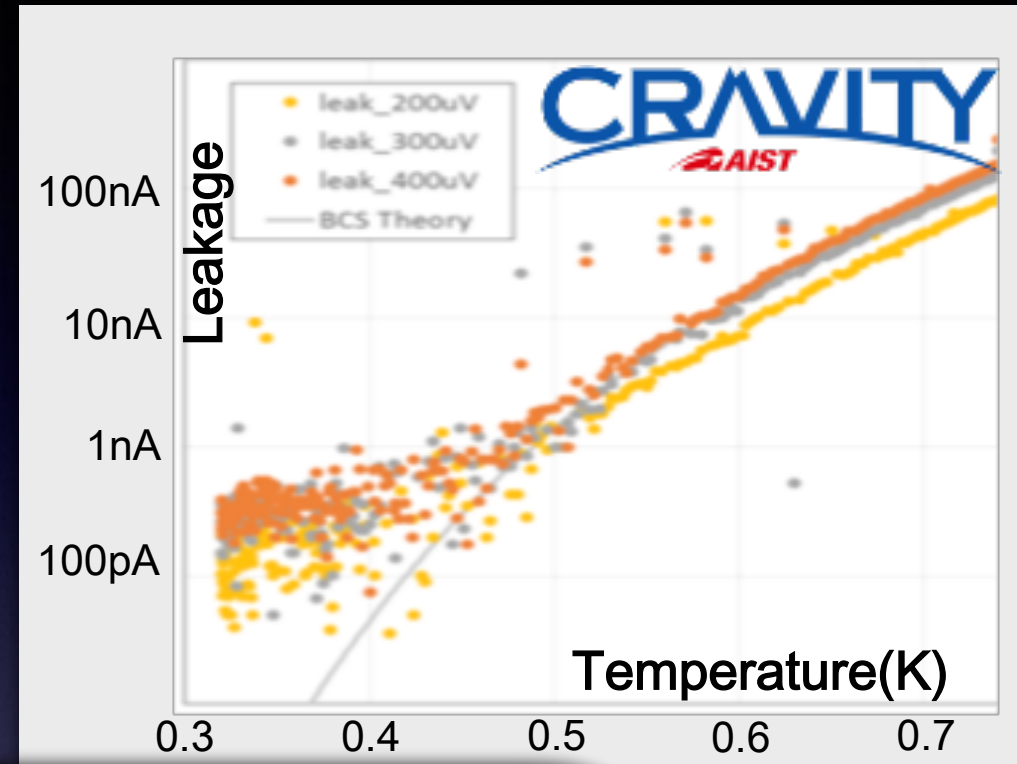
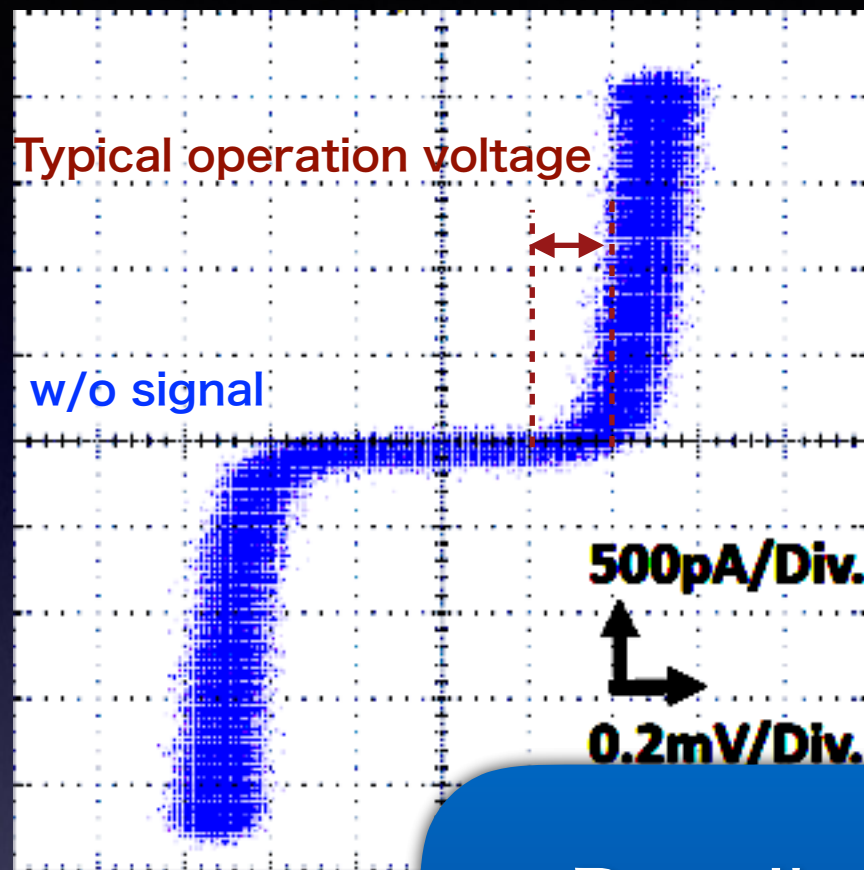


M. Ukibe et al., Jpn. J. Appl. Phys. 51, 010115 (2012)

M. Ohkubo et al., IEEE Trans. Appl. Super, 24, 2400208 (2014)

- Nb/Al/AIO_x/Al/Nb-STJ processed at CRAVITY(*) exhibited excellent quality
*the clean room for analog-digital superconductivity
 - Leakage currents of STJs ($50 \times 50 \mu m^2$) are less than 500pA
- Thicknesses of Nb/Al bi-layer are optimized for the 3He refrigerator
 - The band-gap of this device is $\Delta = 0.6$ mV, operation temperature < 370 mK
 - x5-10 larger signal compared to pure Nb-STJ

The IV characteristic of Nb/Al-STJ



Detail will be reported by
Koya's talk on the 3rd of Dec

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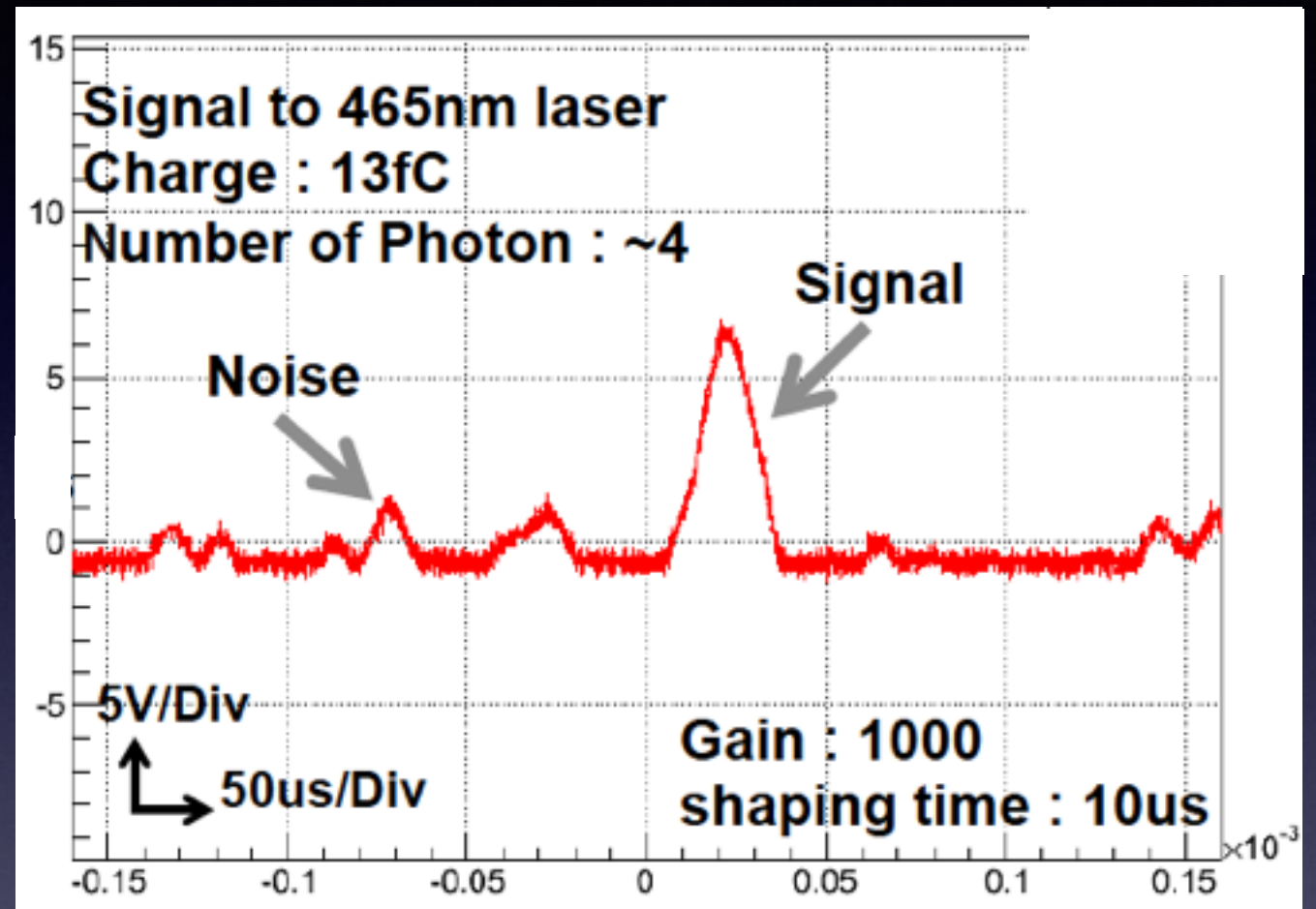
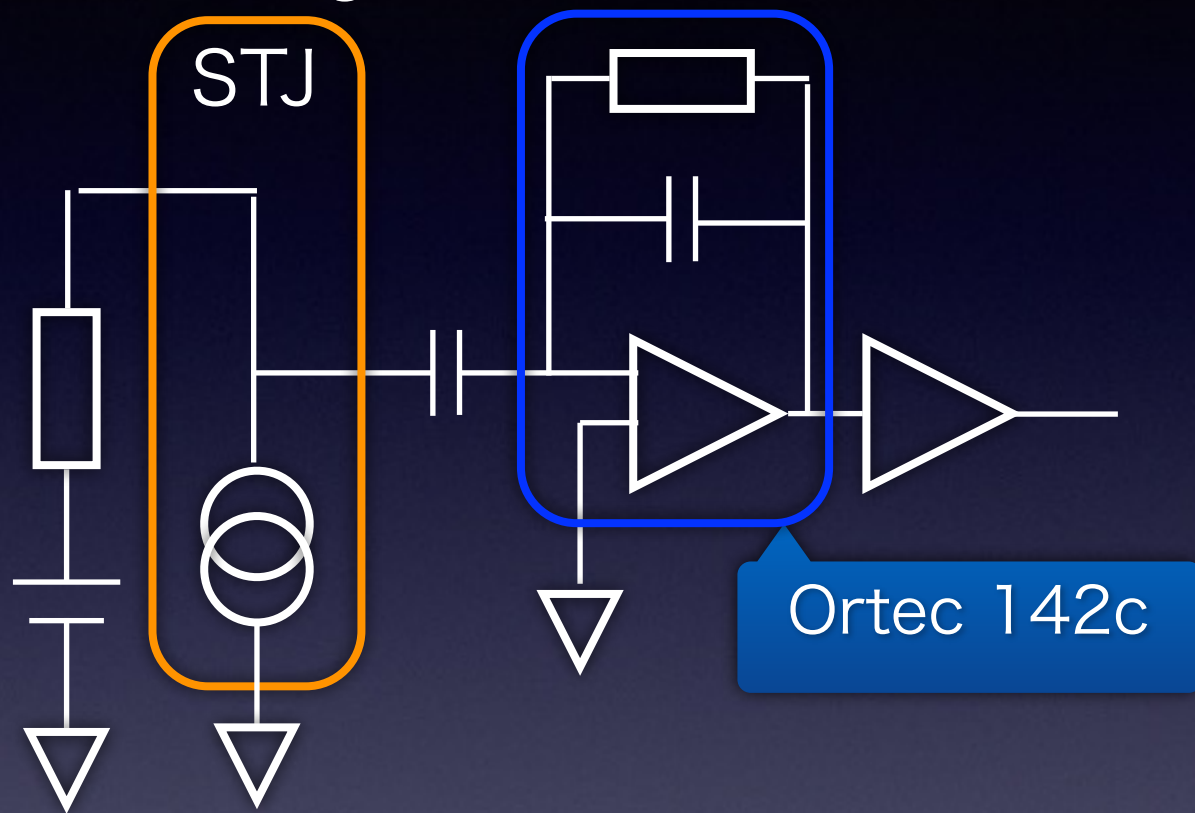
51, 010115 (2012)
Super, 24, 2400208 (2014)

excellent quality
superconductivity

pA

The readout circuit for STJ

3He refrigerator



The output of the STJ for 465nm photon with ordinary amplifier

The cold amplifier is a best solution to solve the following issues

- The transmission loss due to long readout line
- Thermal noises of readout line and amplifier
- Electromagnetic noises from environment

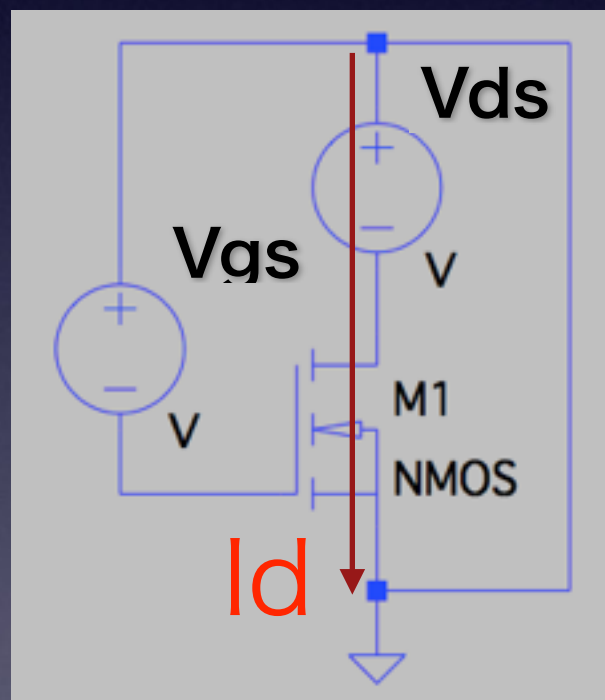
Fully-Depleted Silicon-On-Insulator technology



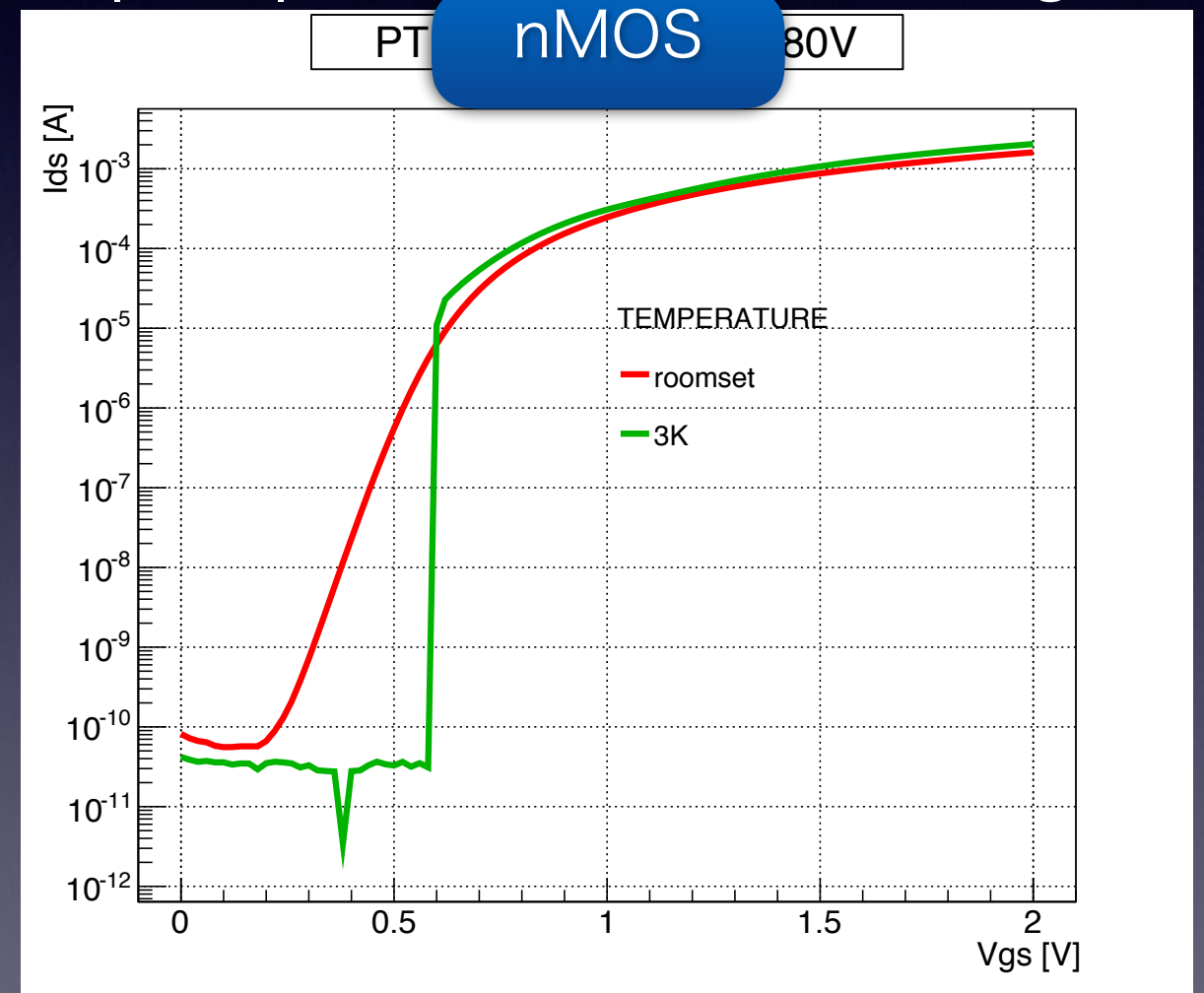
- Fabricated by Lapis semiconductor 0.2um FD-SOI process
- FD-SOI FET: Low noise and low power dissipation
- The source body tie structure(ST) of the FD-SOI FET
 - The body is connected with the source to stabilize body potential
- This FET shows an excellent performance at 4.2 K (*)
 - * H. Nagata et al. AIP conference proceedings, vol.1185, pp267-270,2009
- We confirmed that the FD-SOI FETs operate at 100 mK

I_d - V_g characteristics

V_{ds} is fixed, when I_{ds} is plotted as a function of V_{gs}



I_d - V_g curve of $W/L=10\mu\text{m}/0.4\mu\text{m}$ at $|V_{ds}|=1.8\text{V}$ (saturation region)

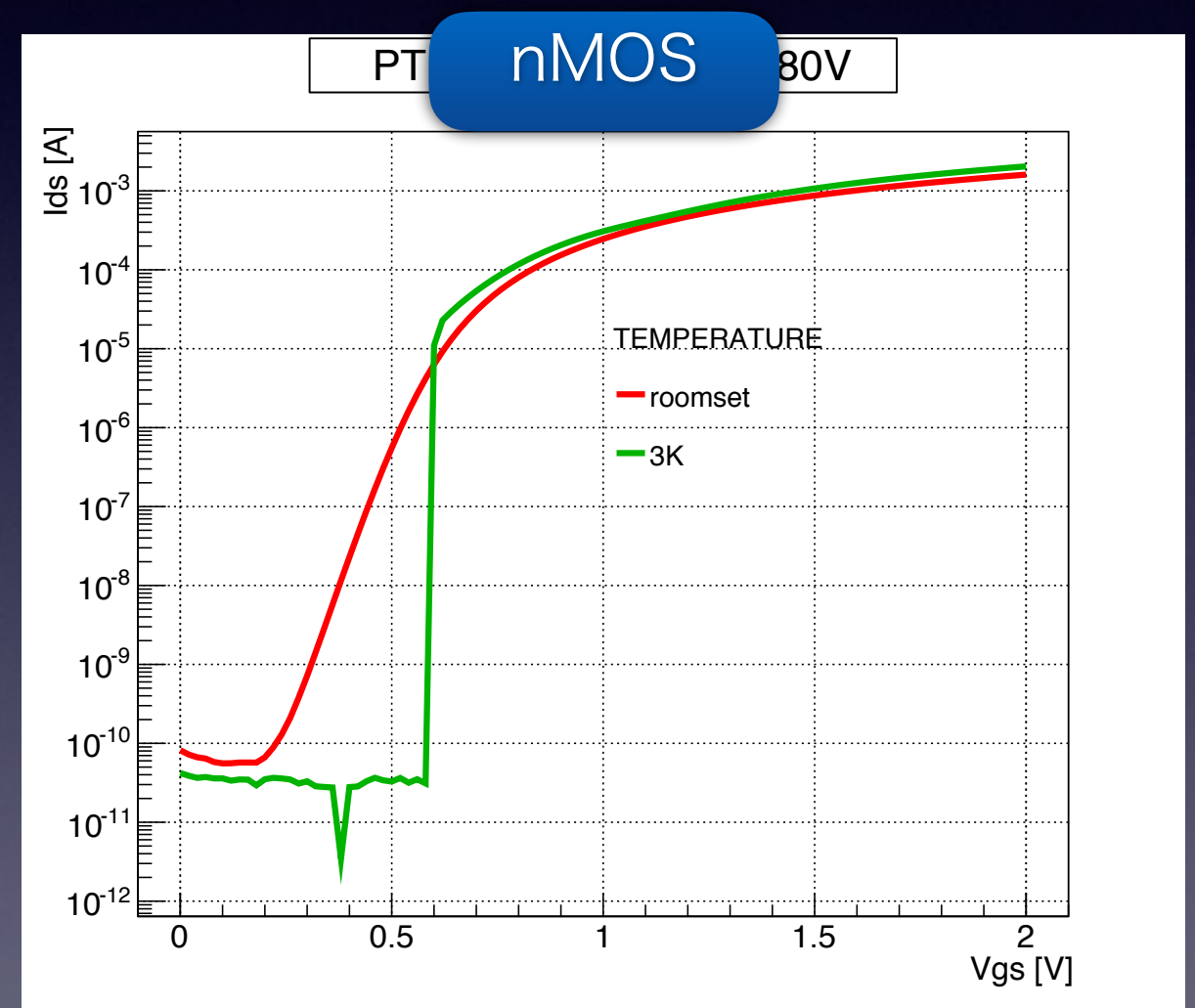
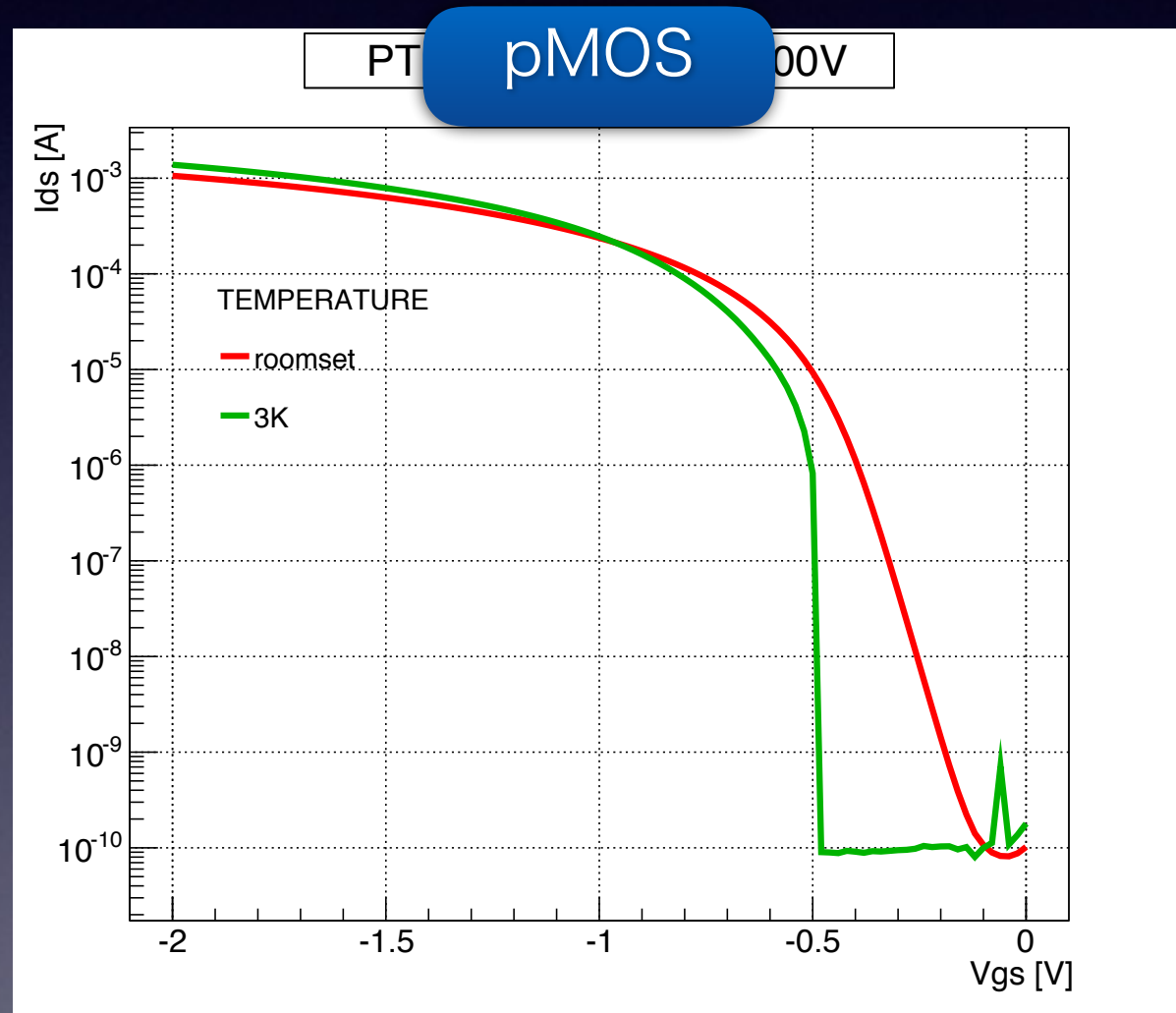


Generally, the FET turns on at typical voltage

The slope of curve(trans conductance) correspond to a gain of amp

FD-SOI FET I_d - V_g curve

I_d - V_g curve of $W/L=10\mu\text{m}/0.4\mu\text{m}$ at $|V_{ds}|=1.8\text{V}$ (saturation region)

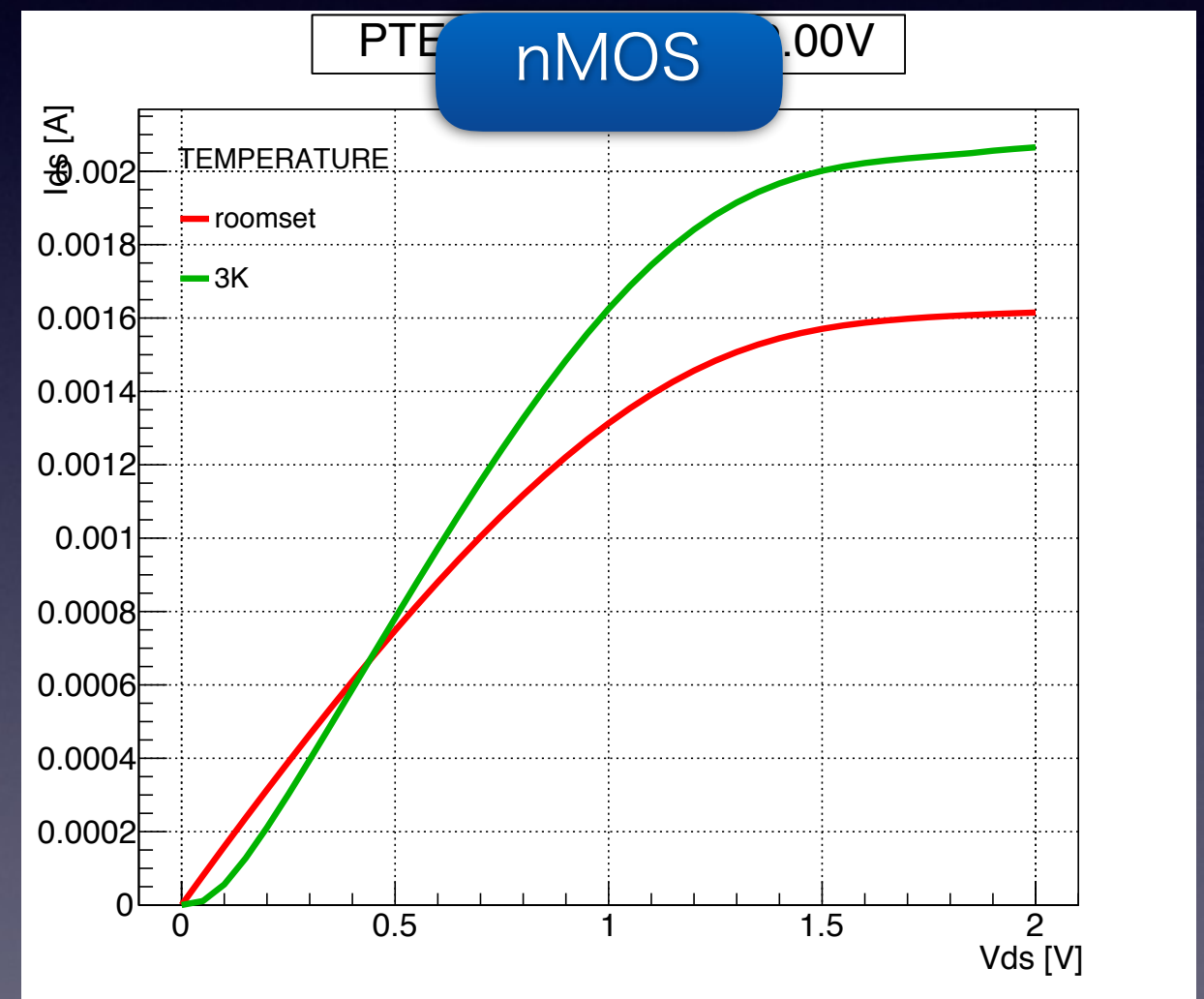
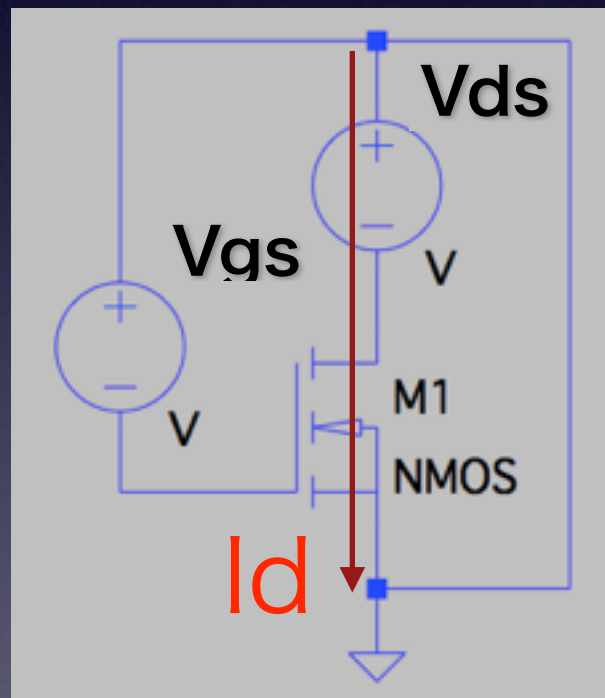


Both pMOS and nMOS show excellent performances at 3K
Increasing the threshold and mobility of the carrier

I_d - V_d characteristics

I_d - V_g curve of $W/L=10\mu\text{m}/0.4\mu\text{m}$
at $|V_{gs}|=2\text{V}$

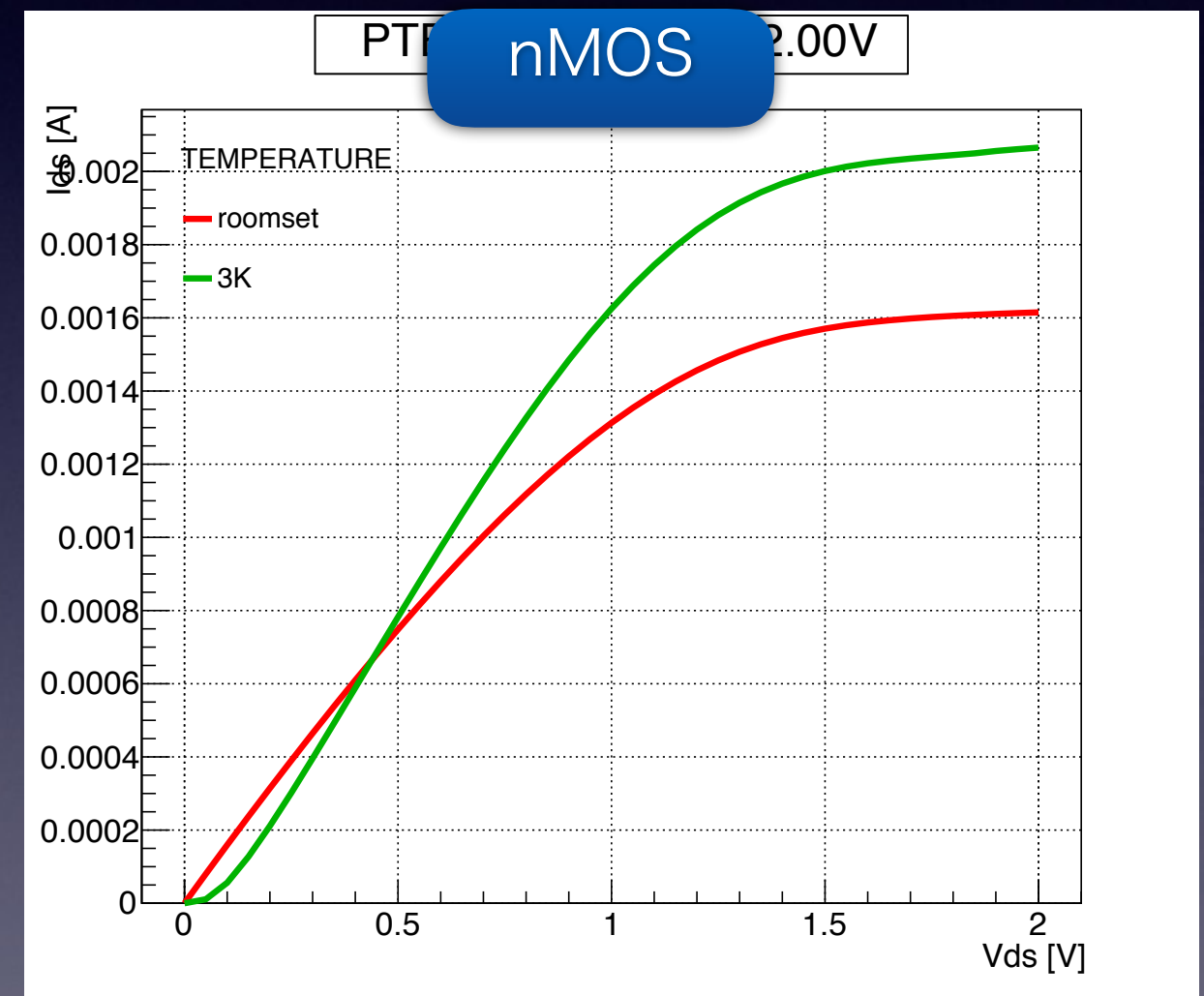
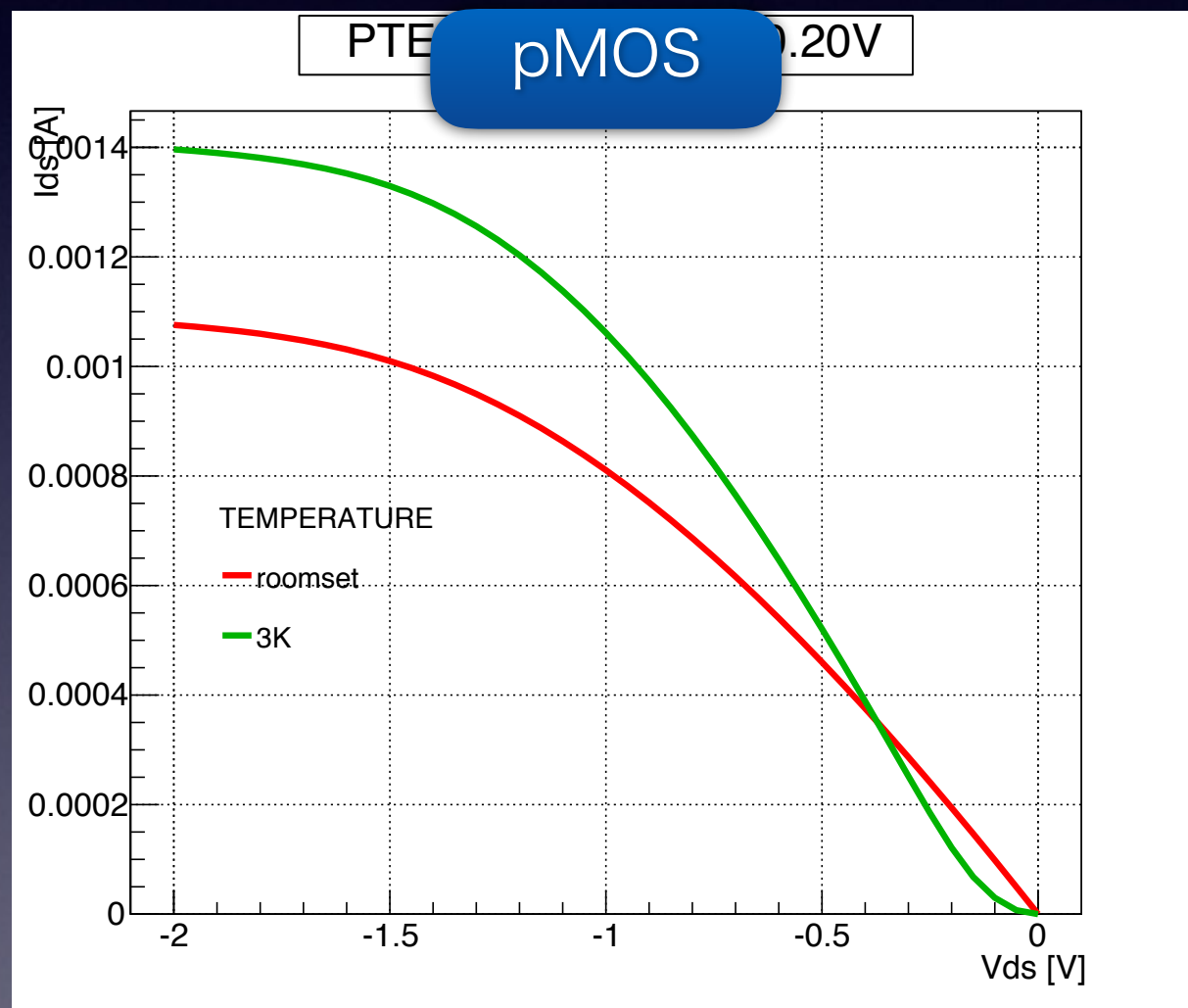
V_{ds} is fixed, when
 I_{ds} is plotted as a function of V_{ds}



The $V_{ds} > V_{ds}-V_{th}$ region called saturated region
The FET acts as constant current source at this region

FD-SOI FET I_d - V_d curve

I_d - V_g curve of $W/L=10\mu\text{m}/0.4\mu\text{m}$ at $|V_{gs}|=2\text{V}$



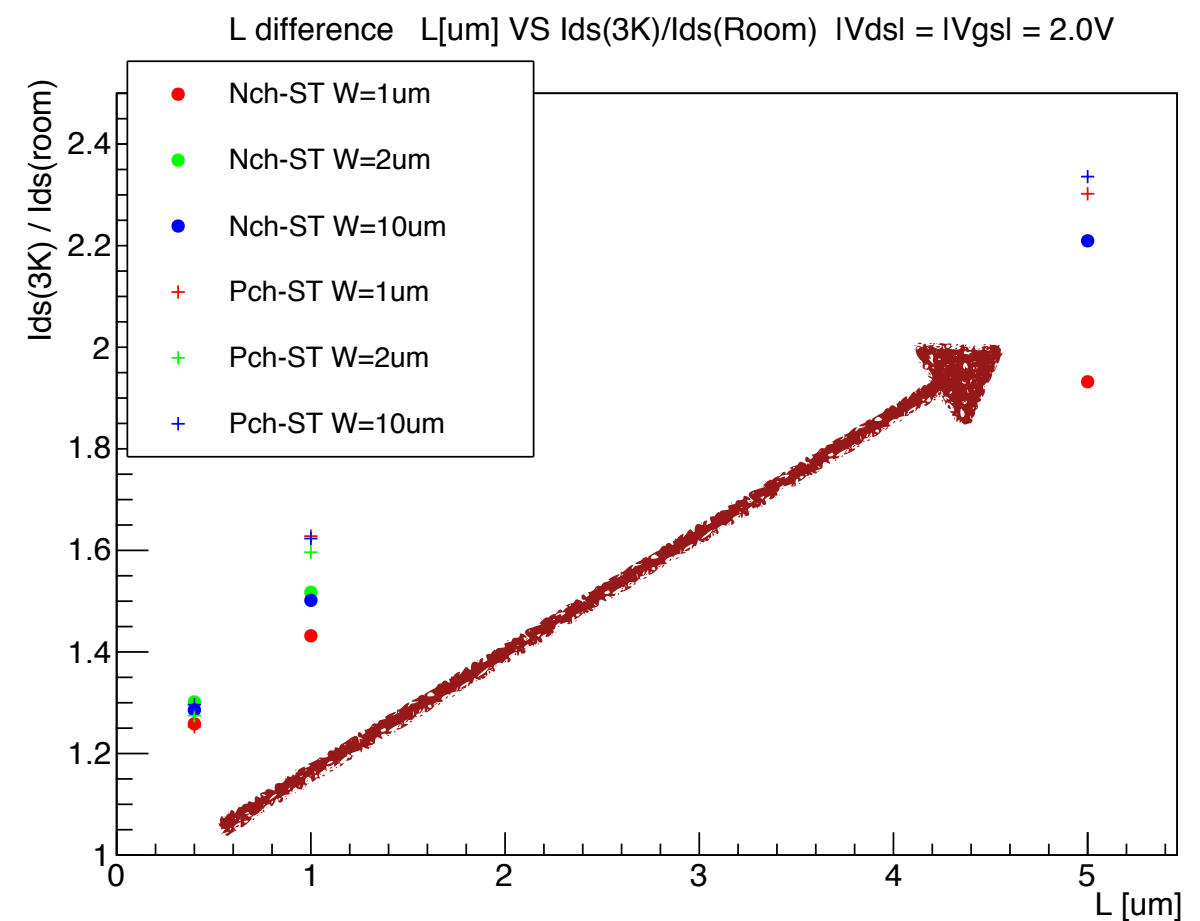
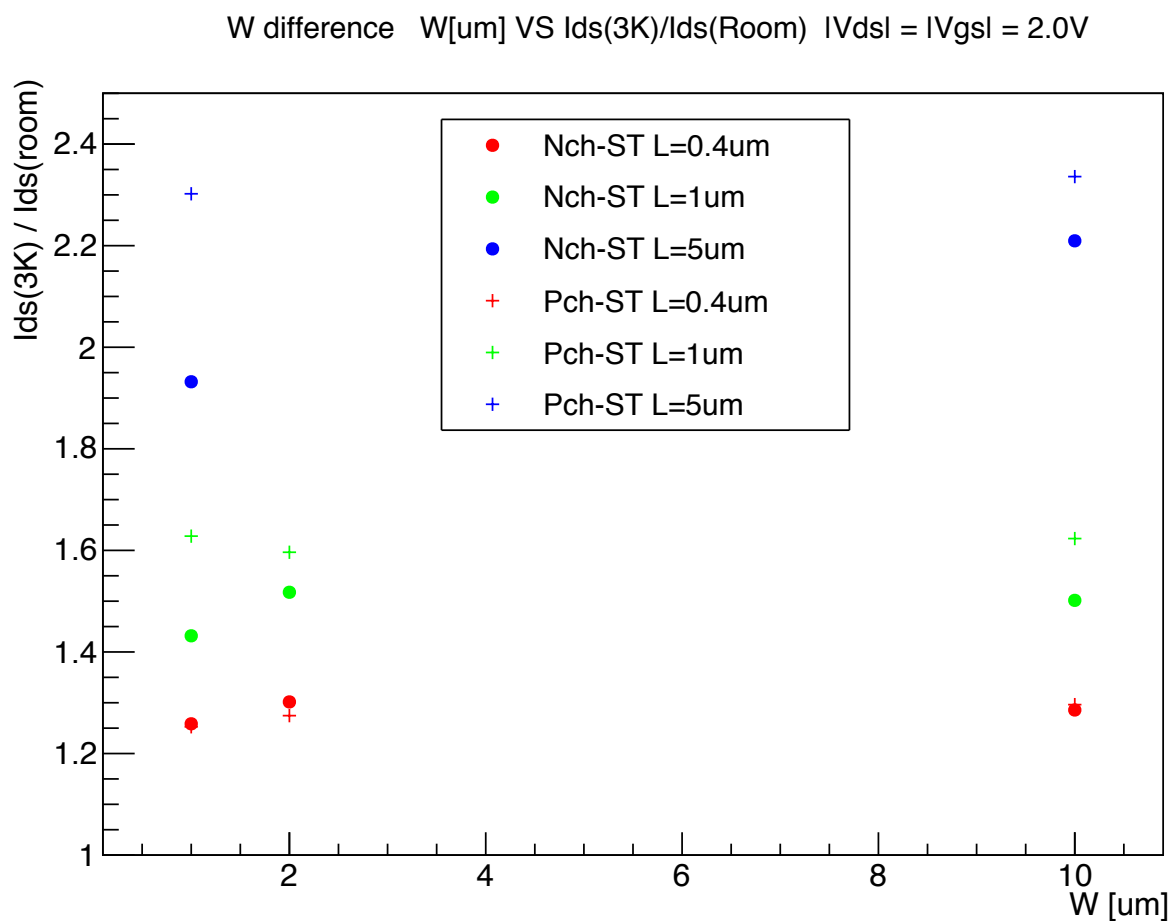
Non linear shapes are observed around $V_{ds}=0$ V

The LDD structure could explain this phenomena (under investigation)

Our circuits uses only saturated region of FETs

The size dependence of the I_d

- Measured W and L range: $W=1-10\mu\text{m}$ and $L=0.4-5\mu\text{m}$



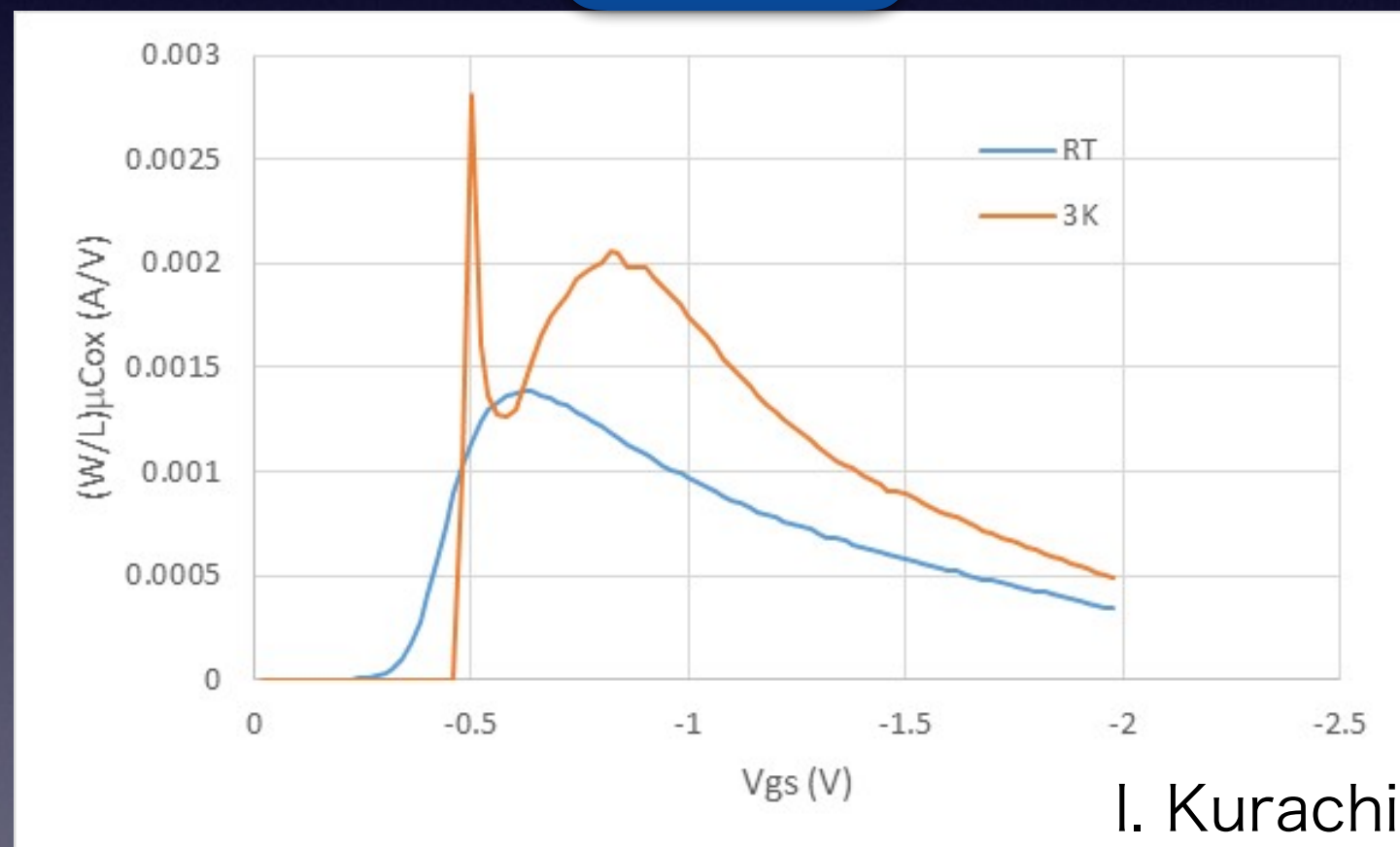
I_d ratio(3K/300K) is independent to the W of FET,
while it has L dependency.

Larger L devices show large ratio

Mobility of carriers @3K

$$I_{d_{sat}} = \frac{1}{2} \frac{W}{L} \mu C_{ox} (V_{gs} - V_t)^2 \rightarrow \mu \propto \left(\frac{\partial \sqrt{I_{d_{sat}}}}{\partial V_{gs}} \right)^2$$

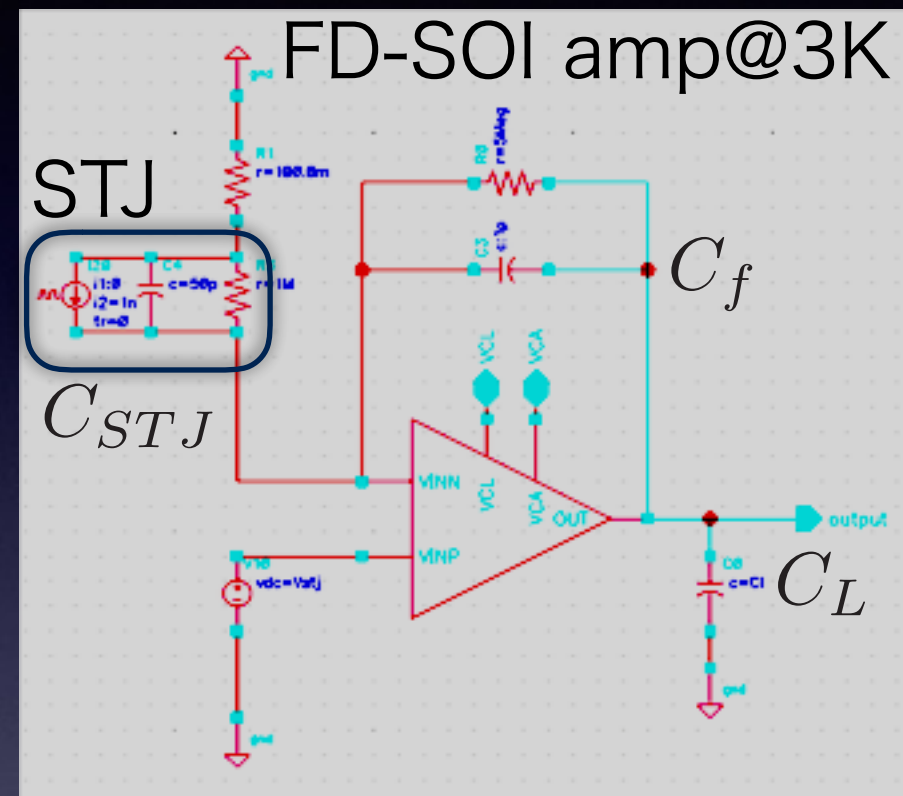
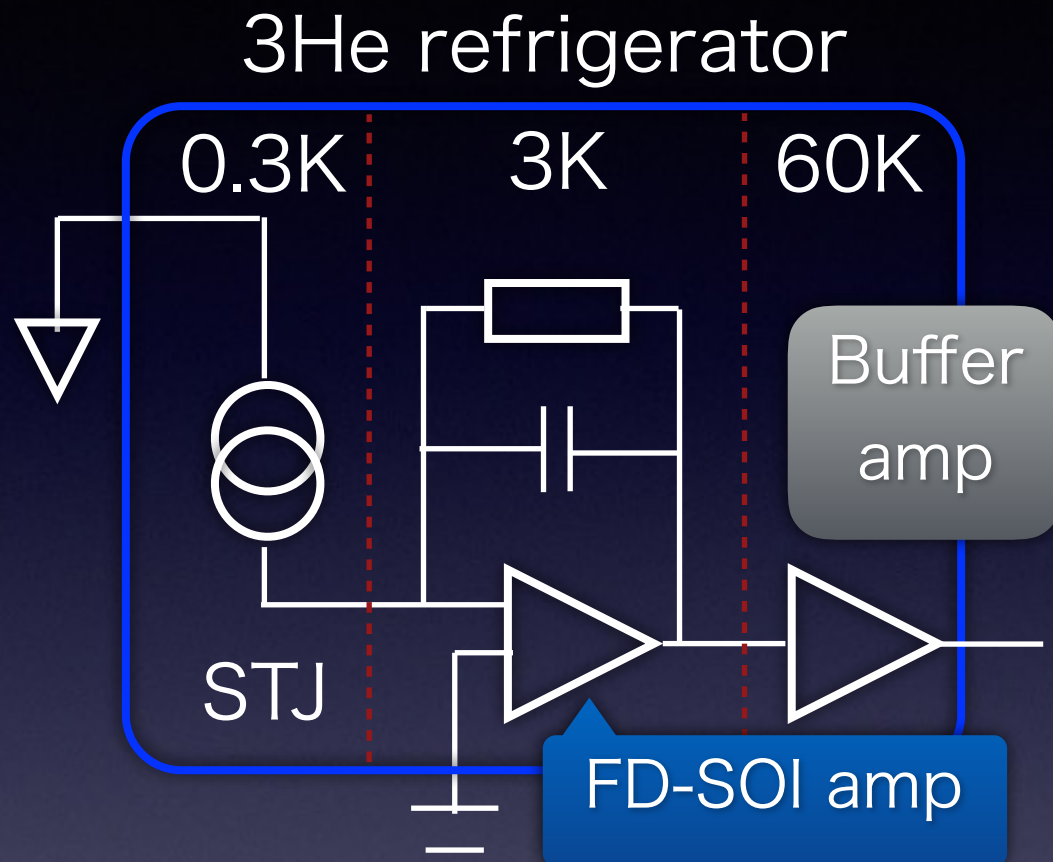
pMOS



Mobility of the carriers increase x1.5 at 3K

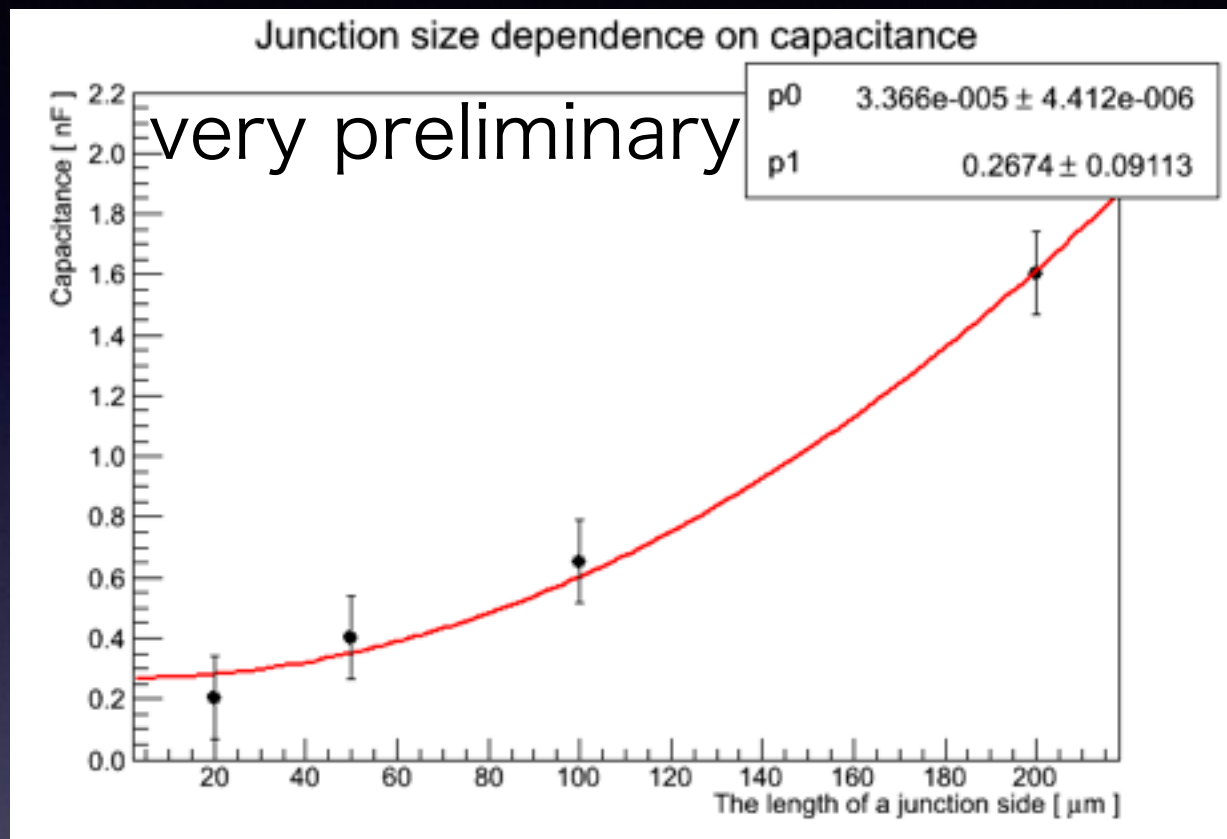
We investigate the cause of first peak

Design of the readout circuit



- There are three stages in 3He refrigerator: 300mK, 3K and 60K
- The STJ is operated on 300mK stage
- The FD-SOI pre-amplifier is operated on 3K stage
- The buffer amplifier drives high load capacitance at 60K
- First target of this circuit is 1.3um single photon counting

Capacitance of the STJ



If we assume the capacitance of STJ depends on only the area of STJ

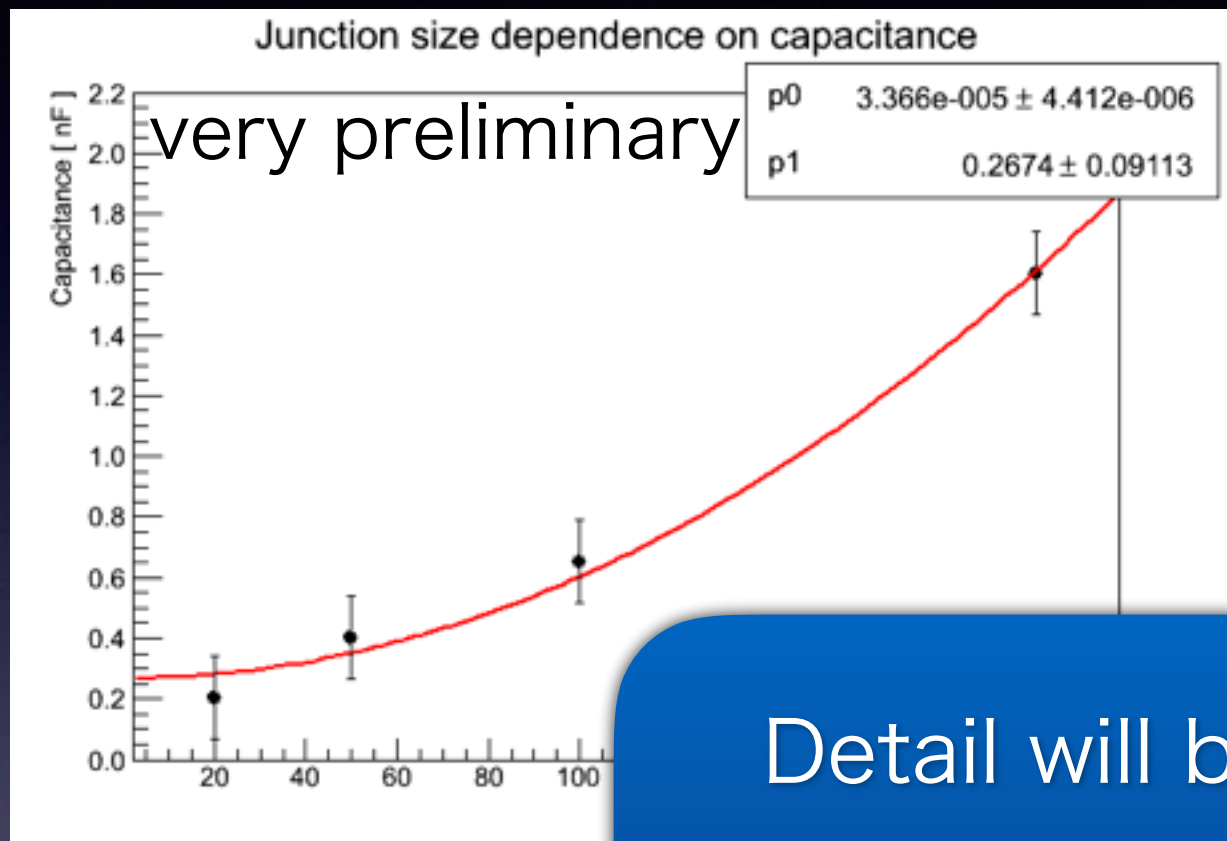
$$C_{all} = C_{RO} + C_{STJ} \times Length^2$$

C_{RO} : Cap. of readout line

C_{STJ} : Cap. of STJ in unit area

- Capacitance of the readout line(0.8nF) is already subtracted
- Capacitance of the STJ is estimated to be $C_{STJ}(\text{nF}) = (3.4 \pm 0.4) \times \text{Area}(\mu\text{m}^2)$
- Parasitic capacitance in the readout line(300mK->300K) is 1.1 ± 0.1 nF
- Capacitance of $20 \times 20 \mu\text{m}^2$ STJ is expected to be 14 ± 2 pF

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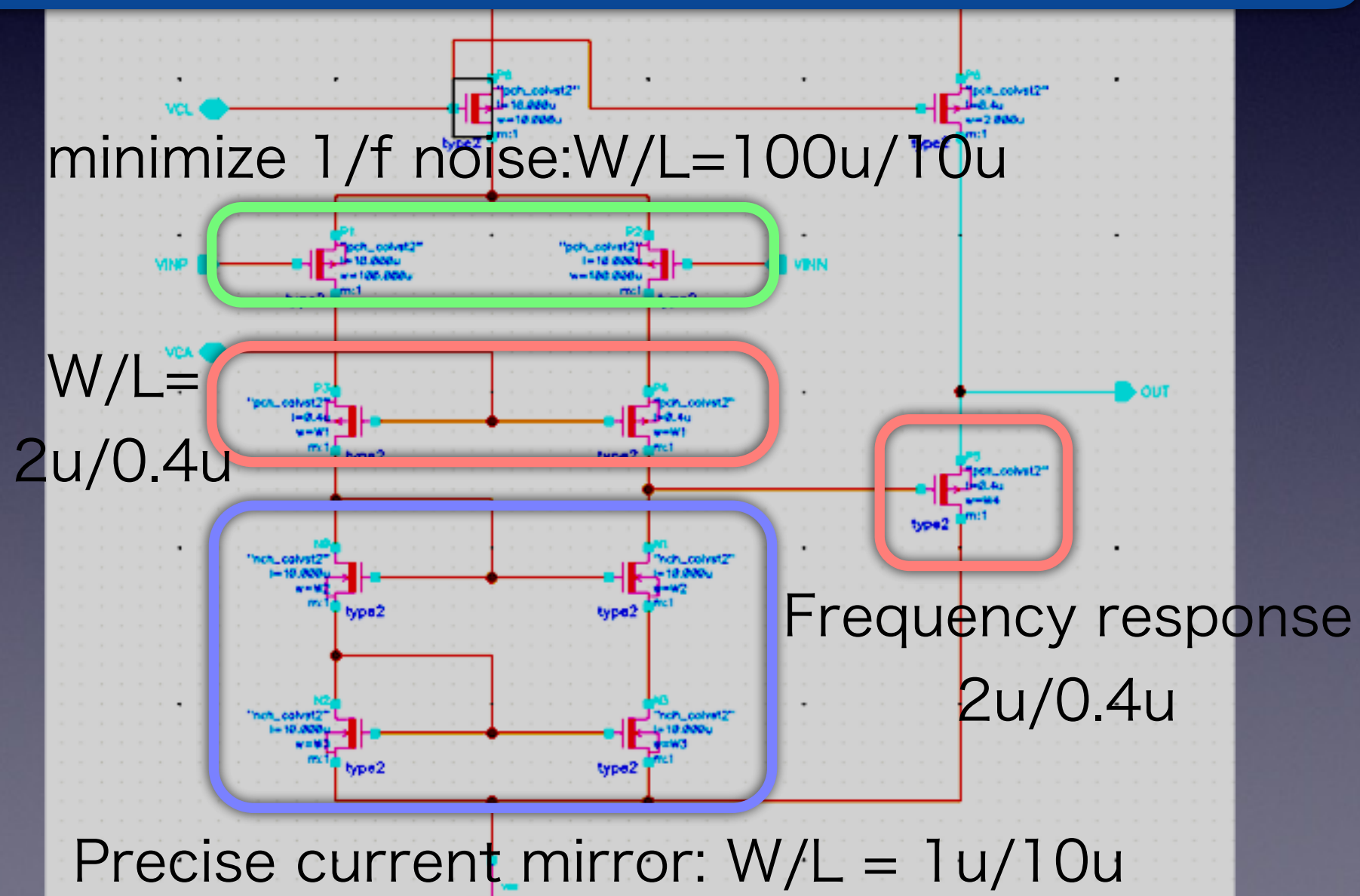
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Detail will be reported by
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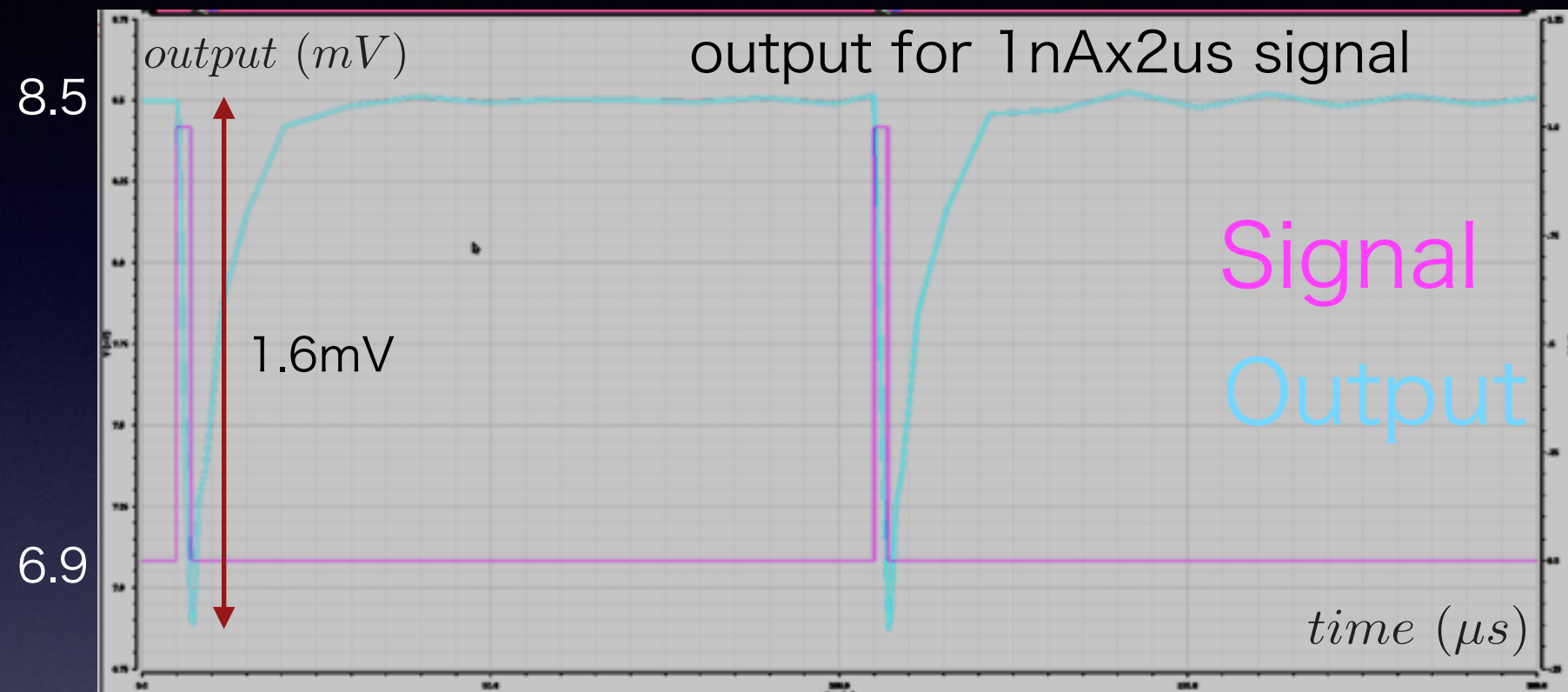
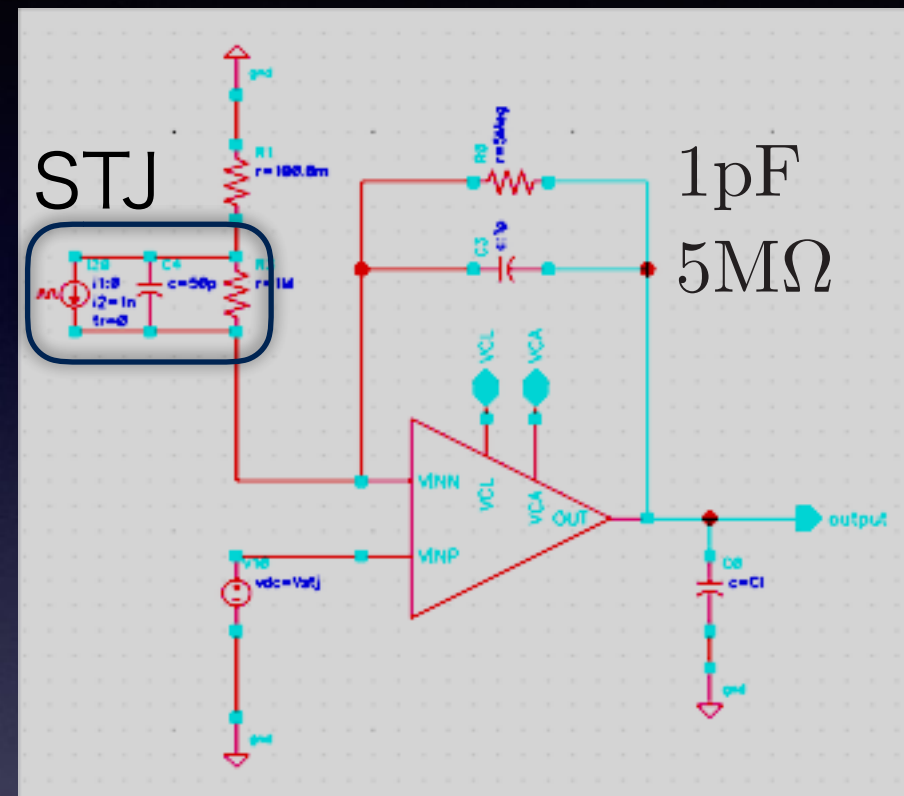
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Candidate of op-amp design

The telescopic cascode structure is employed
Low noise, low power dissipation and fast response



Simulation result



- SPICE simulation(*) is performed with room temperature condition

* Supported by VLSI Design and Education Center(VDEC), the U. Tokyo in collaboration with Synopsys, Inc., Cadence Design Systems, Inc., and Mentor Graphics, Inc.

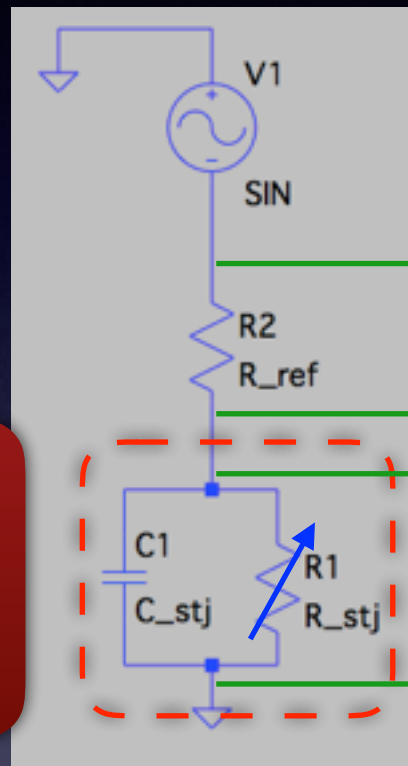
- Feedback capacitance and resistance are 1pF and 5MΩ
- The assumed leakage current of STJ is 400pA@0.4mV
- The detector capacitance and load capacitance are 50pF
- $1\text{nA} \times 2\mu\text{s} = 2\text{fC}$ (600nm single photon) charge produces 1.6mV output

Summary

- We are developing new spectrometer for single FIR photon
- The Nb/Al-STJ is well optimized for our experiment and shows leakage current of 250 pA ($50 \times 50 \mu m$)
- The IV characteristics of FD-SOI FETs are precisely measured at 3K
- The requirement for the cold amplifier is well estimated
- The design candidate of the cold amplifier shows good performance

Capacitance of the STJ

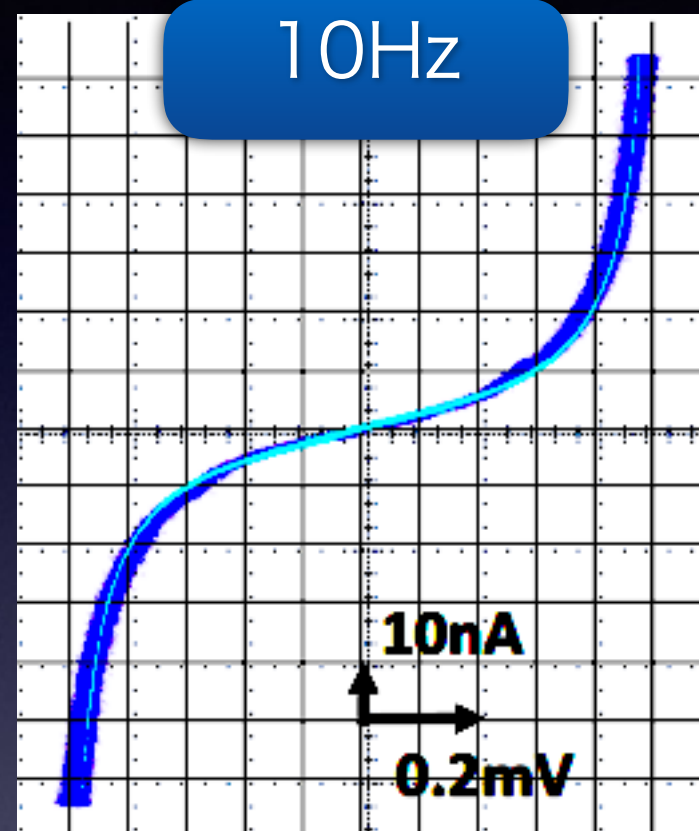
IV measurement: 4-wire sensing



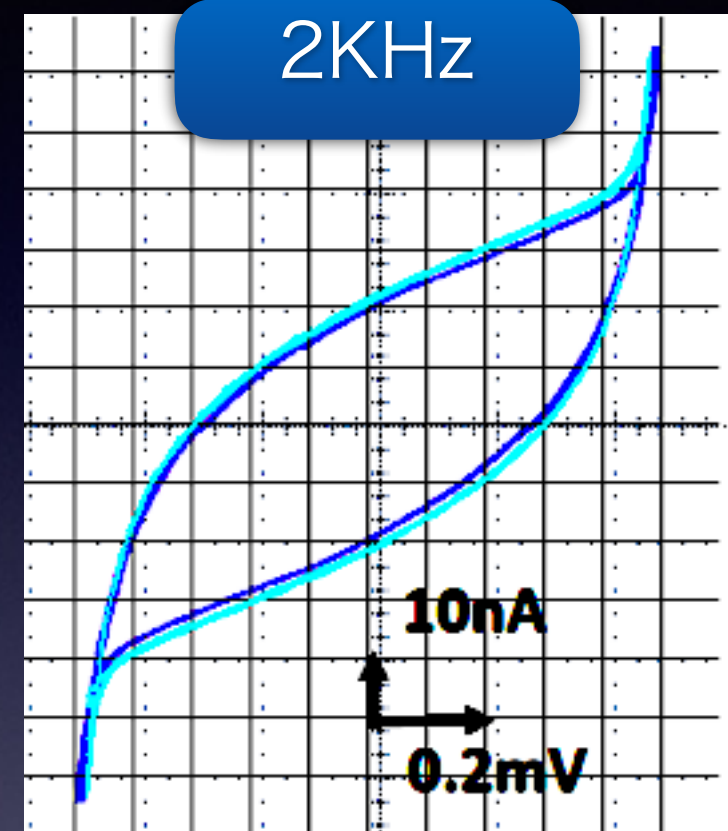
equivalent
circuit
of STJ

Diff.
Amp.

Diff.
Amp.



10Hz



2KHz

- The measured IV curve of STJ(Blue)@10Hz is reproduced using equivalent circuit(cap. + variable res.) in LTSpice(light blue)
- The measured IVs@500Hz and 2kHz are fitted by the simulated curves with various capacitance(0.1nF step)
- The capacitance of the best fit value is taken as the capacitance

$$I_{d_{sat}} = \frac{1}{2} \frac{W}{L} \mu C_{ox} (V_{gs} - V_t)^2 \rightarrow \frac{W}{L} \mu C_{ox} = 2 \left(\frac{\partial \sqrt{I_{d_{sat}}}}{\partial V_{gs}} \right)^2$$